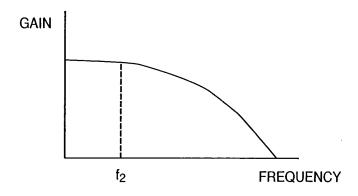
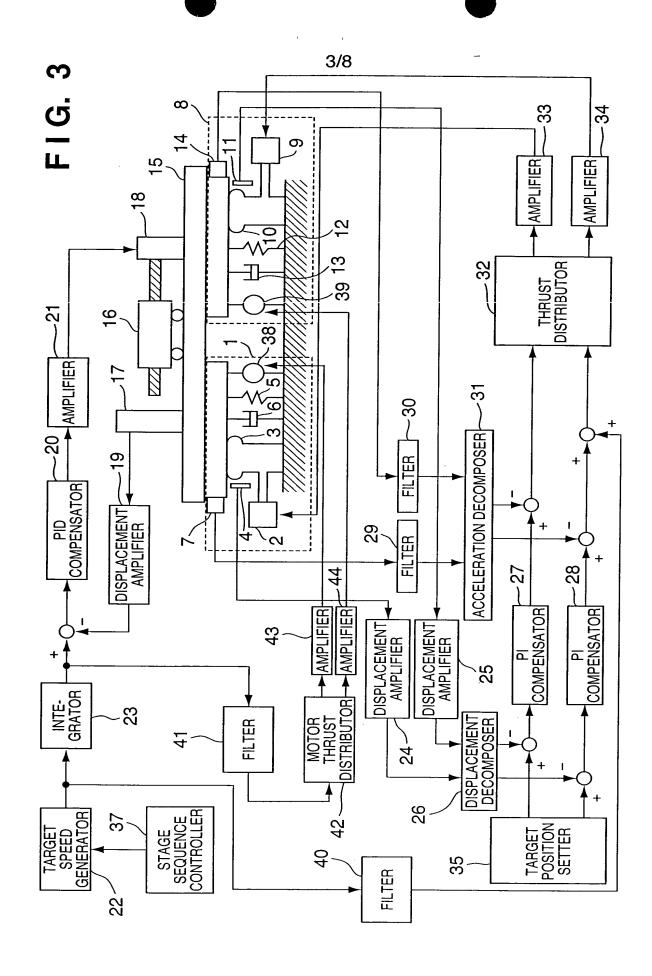
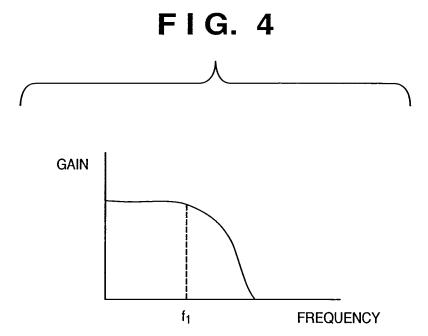


FREQUENCY CHARACTERISTICS OF FILTER 40

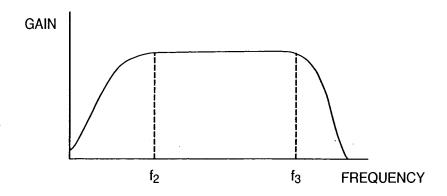


FREQUENCY CHARACTERISTICS OF FILTER 41



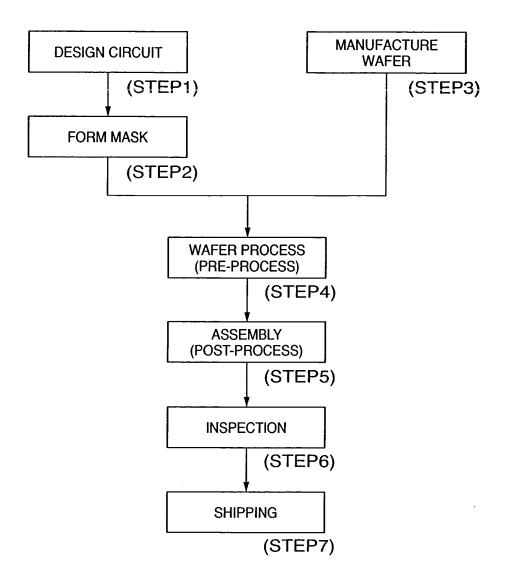


FREQUENCY CHARACTERISTICS OF FILTER 40



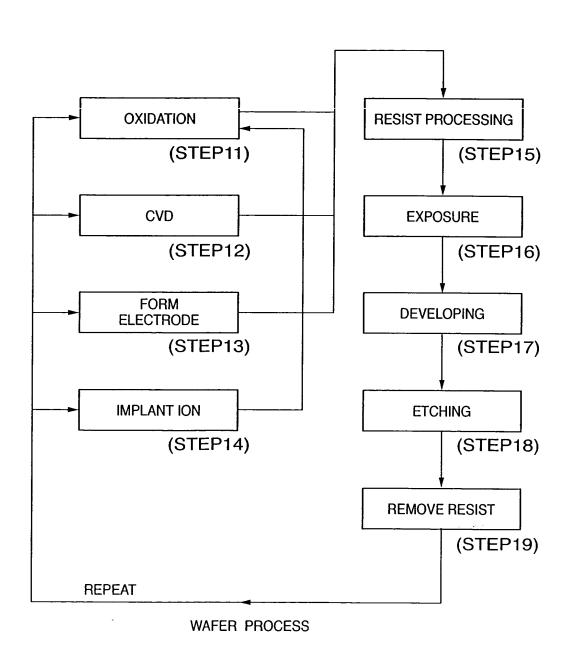
FREQUENCY CHARACTERISTICS OF FILTER 41

FIG. 5



SEMICONDUCTOR DEVICE MANUFACTURING FLOW

FIG. 6



10.2

